# 14.Semiconductor Electronics



Physics Smarl Bookler Theory + NCERT MCQs + Topic Wise Practice MCQs + NEET PYQs



# **Semiconductor Electronics**

# Materials, Devices and Simple Circuits

Materials having the following electrical properties are semiconductors:

- 1. Considerably greater resistivity than that for metals and less than that for insulators.
- 2. Temperature co-efficient of resistance is negative and high.
- 3. Number density (number of charge carriers / unit volume) n is considerably smaller than that for metals but greater than that for insulators.

Silicon and germanium are commonly used semiconducting materials for electronic devices. Now-a-days, silicon is widely used. Both silicon and germanium are tetravalent Z = 14 for silicon and Z = 32 for germanium. Crystal structure of Ge or Si is the same as that of diamond, i.e., pure carbon. The atoms are held in the crystal lattice by covalent bonds.

#### Classification of solids based on the Bond theory of solids



#### Extrinsic semiconductors

- The extra element added to an intrinsic semiconductor is called the *impurity atom*.
- The process of adding impurity into an intrinsic semiconductor is called *doping*.
- A pentavalent atom is used as a *donor impurity*. Eg. P, Sb, As
- A trivalent atom is used as an *acceptor impurity*. Eg. In, B, Al
- In addition to the equal number of electrons and holes already existing due to breaking of bonds (at a temperature)
  - (a) there are as many extra holes as the number of acceptor atoms, in a p-type semiconductor.
  - (b) there are as many extra free electrons as the number of donor atoms, in a n-type semiconductor.

Both p- and n-type semiconductors are electrically neutral.

#### **Effect of doping**

• For the same semiconductor material (whether Si or Ge etc), the pn product is constant independent of the type or density of the impurity and depends only on temperature.

$$p_n n_n = p_p n_p = p_i n_i = p_i^2 = n_i^2$$

where  $n_n$  = electron density,  $p_n$  = minority hole density in a N-type semiconductor

 $p_p$  = hole density,  $n_p$  = minority electron density in a P-type semiconductor

 $p_{i}=\mbox{hole}$  density,  $n_{i}=\mbox{electron}$  density in a intrinsic semiconductor

	Differences between intrinsic and extrinsic semiconductors											
Sl. No.	Intrinsic Semiconductor	Extrinsic Semiconductor										
1.	Pure Ge or Si crystal is known as intrinsic semiconductor.	The semiconductor with specific impurities in controlled quantities is known as extrinsic semiconductor.										
2.	Conductivity is low.	Conductivity is high.										
3.	At any given temperature, the number of electrons is always equal to the number of holes.	The number of electrons and holes are always unequal.										

SI.	p-type	n-type
1.	A p-type semiconductor is obtained by doping a trivalent impurity like B or A <i>l</i> with intrinsic semiconductor.	An n-type semiconductor is obtained by doping a pentavalent impurity like P or As with intrinsic semiconductor.
2.	Majority charge carriers are holes and minority charge carriers are electrons.	Majority charge carriers are electrons and minority charge carriers are holes.
3.	The impurity atom accepts the electron from valence band and contribute to increased conductivity.	The impurity atom donates an electron to conduction band and contributes to increased conductivity.
4.	The acceptor impurity energy level is close to the valence band.	The donor impurity energy level is close to the conduction band.

#### p-n junction or semiconductor diode (unbiased)

The charge depletion region has a thickness of about one-tenth of a  $\mu$ m and the junction voltage is about 0.3 V for a germanium diode and 0.7 V for a silicon diode at 20 °C.



Depletion region

# **Biasing of a p-n junction or (Semiconductor) diode** Forward bias



 $w \rightarrow$  width of depletion region p-n junction diode under forward bias



Barrier potential (a) without battery (b) low batter voltage (c) high battery voltage

#### When in forward bias, a diode

- offers negligible (ideally zero) resistance
- behaves like a closed switch
- external voltage opposes the junction voltage.

#### **Reverse bias**



#### When in reverse bias, a diode

- offers very large (ideally infinite) resistance
- behaves like an open switch
- external voltage aids the junction voltage.

At a very large reverse voltage, reverse breakdown occurs and, hence, a large current flows through the device. This voltage is about 400 V for germanium and 1000 V for silicon.

#### **Rectifiers**

A rectifier is a circuit that converts an ac signal into a dc signal. The unidirectional property of a diode is used in the construction of a rectifier.

#### Half wave rectifier



The output of a half-wave rectifier, is still pulsed, and hence it is not pure dc. (Thus a filter is required to remove the ripples)

 $\mathbf{f}_{output} = \mathbf{f}_{input}$ 



5

The output of a full wave rectifier is still pulsed and hence, it is not pure dc. (Thus a filter is required to remove the ripples)

 $f_{output} = 2f_{input}$ 

#### **Capacitor input filter (Shunt capacitor filter)**

#### **Need for filter**

Even through the output of a rectifier is unidirectional, to does not have a steady value. To get, steady output, a capacitor is connected across  $R_L$  (the output terminals) (an inductor connected in series with  $R_L$  or a suitable combination of L and C also can be used) which function as a filter.



The product  $R_LC$  is called the time constant of the filter circuit. Larger the value of  $R_LC$ , better is the filtering action. Generally a capacitor of large capacitance is used.

## Special purpose p-n junction diodes

#### Zener diode

Zener diode is a special purpose diode designed to operate in its reverse breakdown region. The breakdown voltage is called the *zener voltage*.



#### Zener diode as a voltage regulator



Zener diode as voltage regulator

- Let us assume an unregulated dc voltage  $V_1$  be applied as the input, as shown in the figure.
- If  $V_1 < V_Z$  there, is no voltage across the zener diode
- If  $V_1 > V_Z$ , then voltage across the zener diode is  $V_Z$  and the remaining voltage appears across  $R_L$ . If  $V_1$  varies, then  $(V)_{R_s}$  also varies keeping  $V_Z$  constant.

Voltage across zener remains same independent of the current drawn by the device. Thus, a zener diode in reverse bias maintains constant voltage across the load independent of variation in the input voltage and in the load.

#### **Optoelectronic junction devices**

Semiconductor diodes which generate charge carriers by photons are called optoelectronic devices. This includes.

- Light emitting diodes (LED) which convert electric energy into light
- Photo diodes used for detecting optical signals
- Photovoltaic devices (solar cells) which convert light into electrical energy

#### Light emitting diode (LED)

LED is a heavily doped p-n junction when in forward bias

emits light (in visible, ultraviolet or infrared region). When a diode is in forward bias, electrons from the n-type material recombines with the holes in the p-type material, near the junction. Due to this recombination energy is released in the form of heat and light.

In Ge and Si diodes, much of their energy is dissipated in the form of heat within the body of the diode.

This is due to *non-radiative recombination* and light emitted is insignificant. For this reason, Si and Ge are not used in the construction of a LED.

Diodes made of Gallium arsenide (Ga As) when in forward bias emit light in the infrared region during the recombination process at the p-n junction.

#### V-I characteristics of LED

V-I characteristics are similar to that of a p-n junction diode made of Si or Ge. The threshold voltages are much higher and different for each colour. The reverse breakdown voltages of most LEDs are small, about 5 V.

#### Advantages of LED over conventional incandescent lamp

- 1. Low operational voltage and less power consumption.
- 2. Fast action and no warm-up time required.
- 3. The bandwidth of emitted light is 100 Å to 500 Å. Light emitted is fairly monochromatic.
- 4. Long life and rugged.

#### Photodiode



#### Symbol of a photodiode

Basic biasing arrangement of photodiode

A photodiode is a special purpose photosensitive semiconducting diode operated in the reverse biased condition. When light is incident on the junction, the junction resistance decreases rapidly with the increase in the intensity of light.

#### Solar cells

A solar cell is a p-n junction which generates emf when light radiation is incident on it.



### p-n junction solar cell

The top p-type material is made very thin so that the photons reach the junction. The contact to the p-type material is made through an outer ring deposited on it while a metallic contact is established to the bottom of the n-type material. A protective glass covering is provided for the top surface.

Reason for wide use of the materials like Si, Se and Ga As

- i. Semiconductors with band gap  $E_g \approx 1.5$  eV has a higher conversion efficiency, greater stability and less fatigue.
- ii. They have higher absorption coefficients.
- iii. These materials have excellent temperature characteristics. They can withstand extreme high or low temperatures without a significant drop-off in efficiency.

Materials with smaller band gaps are not suitable since most of the radiation will be absorbed on the top layer of solar cell and may not reach the depletion region. For effective electron-hole separation due to junction field, they must be generated in the junction region only.

#### **Transistor**

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A transistor is a three terminal semiconducting device, which has a thin wafer of one type of extrinsic semiconductor between two layers of the other type.

A transistor with an n-type wafer between two p-type wafers, is called a p-n-p transistor. Similarly a transistor which has a p-type of wafer between two n-type layers, is called n-p-n transistor.

The thin layer in the middle region of the transistor is called the *base*. The two layers on either side of the base are called *emitter* and *collector*.

#### For any transistor

- The size of the base is the least and that of the collector region is the highest.
- Doping level is least in the base and highest in the emitter region.

The function of the emitter is to emit the majority charge carriers, and that of the collector is to collect the majority charge carriers. The function of the base is to modify the emitter current.

The arrows in the circuit symbol of n-p-n and p-n-p transistor indicate the direction of conventional current.



• Though both the emitter and collector are made of same type of the extrinsic semiconducting material, they are not interchangeable because of

(a) different doping levels

(b) different physical sizes.

• A transistor as a whole, is a single crystal doped with suitable materials and not a combination of 3 pieces of different crystals.

#### **Operation of a transistor**



he emitter base junction should be forward biased and the collector base junction should be reverse biased.

If  $I_E$ ,  $I_B$  and  $I_C$  represent the emitter current, the base current and the collector current respectively, then  $I_E = I_B + I_C$ .

 $I_B$  is of the order of micro ampere and  $I_E$  and  $I_C$  are of the order of milliampere. As an approximation, we can write  $I_E \approx I_C$ .

Consider an n-p-n transistor. The majority charge carriers namely, free electrons, are transferred from the low resistance emitter-base junction (forward bias) to the high resistance collector-base junction (reverse bias). Hence, the device is called **transfer - resistor**-abbreviated as **transistor**.

Since, nearly the same current flows from emitter to collector; and the collector base junction offers very high resistance compared to the emitter base junction; there is an amplification of power. Thus, *a transistor can be used as a power amplifier*.

#### **Transistor configurations (modes)**

#### Transistor configurations

Amplifier circuits using transistors can be classified into three categories determined by the circuit arrangement and the load.

#### (a) Common base configuration

Input signal is provided between the emitter and the base. The output signal appears across the collector and the base.



The current gain ( $\alpha_{dc}$ ) in CB mode of a transistor is given by  $\alpha_{dc} = \frac{I_C}{I_E}$ 

 $\alpha_{dc}$  is in the range of 0.95 to greater than 0.99 but less than 1.

The current amplification factor ( $\alpha_{ac}$ ) in CB mode is defined by

$$\alpha_{\rm ac} = \left(\frac{\Delta I_{\rm C}}{\Delta I_{\rm E}}\right)_{\rm V_{\rm CB}=\rm constant}$$

Generally,  $\alpha_{ac}$  and  $\alpha_{dc}$  are quite close.

#### (b) Common emitter configuration

Input signal is provided between the emitter and the base. Output signal appears across the collector and the emitter.



The current amplification factor ( $\beta_{ac}$ ) in CE mode is given by,  $\beta_{ac} = \left(\frac{\Delta I_{C}}{\Delta I_{C}}\right)$ 

$$\beta_{\rm ac} = \left(\frac{\Delta I_{\rm C}}{\Delta I_{\rm B}}\right)_{\rm V_{\rm CE = constant}}$$

1

 $\beta$  is in the range of about 50 to 300

#### (c) Common collector configuration

Input signal is provided between the base and the collector. Output signal appears across the emitter and the collector.



- CC configuration is also called emitter follower. The common-collector configuration is used for impedance matching purposes because it has a high input impedance and low output impedance. In the case of common-base and common-emitter configurations, input impedance is low and output impedance is high. Because of this characteristic, CE and CB configurations are widely used for amplification purposes.
- A transistor is most widely used in CE configuration. npn-Si transistors are widely used. With pnp transistors, the polarities of the external power supplies must be reversed.

#### Relation between $\alpha_{dc}$ and $\beta_{dc}$

We have for a transistor  $I_E = I_B + I_C$ 



•  $\alpha_{dc}$  and  $\beta_{dc}$  of a transistor are temperature dependent.

#### **Common emitter characteristics**



**Features of output characteristics** 

i. In the active region,  $i_{c}$  increases slowly with  $V_{\text{CE}}.$ 

ii. In the saturation region,  $i_c$  decreases rapidly as  $V_{CE}$  decreases [ $V_{CE} < 1$ ]. This occurs as  $V_{CE}$  drops below the value of  $V_{BE}$ . The collector-base junction is then forward biased. In this condition, both EB junction and CB junction are forward biased. This is called saturation region as  $I_c$  no longer depends upon the input current  $I_B$ .

iii. In the active region, a small input current I<sub>B</sub> produces a large collector current I<sub>C</sub> (output current)

iv. The collector current is not zero when  $I_B$  is zero. It has a value of  $I_{CEO}$ , the reverse leakage current.

#### Transistor as a switch

If a very large base current is present in a transistor in a common emitter configuration, the transistor will be driven into *saturation*. On the other hand, if the base current is reduced to zero, the transistor is placed in cut-off. When a BJT is operated strictly between these two modes, it acts as a switch.



#### **Transfer characteristics – Transistor switch**

When  $v_i$  is low, the transistor is not conducting. It is said to be switched OFF. When the input is high, transistor operates at saturation, it is said to be switched ON.

#### Transistor as an amplifier – npn CE amplifier Principle

A small change in the base current causes a larger change in the collector current. This is the underlying principle of the transistor amplifier. The condition necessary for the amplifier to work is that *the base emitter junction should be forward biased and collector base junction should be reverse biased*.



#### AC voltage gain

 $\mathbf{A}_{v} = -\beta_{\mathrm{ac}} \left( \frac{\mathbf{R}_{\mathrm{L}}}{\mathbf{r}_{\mathrm{i}}} \right)$ 

The negative sign indicates that the output is inverted w.r.t. the input.

#### **Power gain**

In CE-mode, a transistor amplifier produces a current gain ( $\beta_{ac}$ ) and also a voltage gain ( $A_v$ ). Thus, power gain ( $A_p$ ) is given by

$$A_p = \beta_{ac} A_v$$

Since both  $\beta_{ac}$  and  $A_v$  are greater than 1, there will be a power gain. However, a transistor is not a power generating device. The energy for the higher ac power at the output is provided by the battery.

#### **Feedback amplifier**

The process in which a fraction of the amplifier output is fed back to the input circuit is called feedback. It helps to control the output of the amplifier.

If the feedback voltage is such that the returning signal is in phase with the input signal, the amplitude of the input signal increases. This is called **positive feedback or regenerative feedback.** This principle is used in the construction of oscillators. Positive feedback produces excessive distortion and not suitable in amplifiers.

If the feedback voltage is such that the returning signal is in opposite phase with the input signal, the amplitude of

input signal decreases. This is called **negative feedback or degenerative feedback.** The advantages of negative feedback are stable gain, less distortion and more bandwidth. Hence, it is used in amplifiers.

#### Illustrations

1. The density of electrons and holes in a pure germanium sample at room temperature are equal and its value is  $3 \times 10^{16}$  per m<sup>3</sup>. On doping with aluminium, the hole density increases to  $4.5 \times 10^{22}$  per m<sup>3</sup>. Then the electron density in doped germanium is

(A) 
$$2 \times 10^{10} \text{ m}^{-3}$$
  
(C)  $4.5 \times 10^{-10} \text{ m}^{-3}$ 

 $n^2$ 

(B)  $5 \times 10^9 \text{ m}^{-3}$ (D)  $3 \times 10^9 \text{ m}^{-3}$ 

#### $(3 \times 10^{16})^2$ 2 10<sup>10</sup> -3

The electron and hole concentration in a semiconductor in thermal equilibrium is given by  $n_n n_n = n_i^2$ 

$$n_e = \frac{1}{n_h} = \frac{1}{4.5 \times 10^{22}} \approx 2 \times 10^{10} \text{ m}^2$$

2. A block of pure silicon at 300 K has a length of 10 cm and an area of  $10^{-4}$  m<sup>2</sup>. If a battery of emf 2 V is connected across it, the electron current is (Given: mobility of electrons is  $0.14 \text{ m}^2 \text{ V}^{-1} \text{ s}^{-1}$  and electron density is  $1.4 \times 10^{16} \text{ m}^{-3}$ )

(A) 
$$6.72 \times 10^{-4}$$
 A (B)  $6.72 \times 10^{-5}$  A (C)  $6.72 \mu$ A (D)  $0.56 \mu$ A

Ans (D)

Ans (A)

Given  $\mu_e = 0.14 \text{ m}^2 \text{ V}^{-1} \text{ s}^{-1}$ ,  $n_e = 1.4 \times 10^{16} \text{ m}^{-3}$ , l = 10 cm = 0.1 m,  $A = 10^{-4} \text{ m}^2$  and V = 2 volt.

The electric field in the block is

E = 
$$\frac{V}{1} = \frac{2}{0.1} = 20 \text{ V m}^{-1}$$

The drift speed of electrons is

$$v_e = \mu_e E = 0.14 \times 20 = 2.8 \text{ m s}^{-1}$$

$$= (1.4 \times 10^{16}) \times (1.0 \times 10^{-4}) \times (1.4 \times 10^{-19}) \times 2.8$$

 $\Box 5.6 \times 10^{-7} \text{ A} = 0.56 \ \mu\text{A}$ 

3. A piece of copper and silicon are first heated to a temperature of 150°C and then gradually cooled. During the cooling

 $\therefore$  Electron current  $I_e = n_e Ae v_e$ 

- (A) the resistance of copper increases and that of silicon decreases
- (B) the resistance of silicon increases and that of copper decreases
- (C) the resistance of both silicon and copper increase
- (D) the resistance of both copper and silicon decrease

#### Ans (B)

Copper is a conductor whose resistance decreases with decrease in temperature whereas silicon is a semiconductor whose resistance increases with decrease in temperature (semiconductors have negative temperature coefficient of resistance).

The electrical conductivity of a semiconductor specimen is found to increase when electromagnetic radiation of wavelength shorter than 2480 nm is incident on it. The band gap in (eV) for the semiconductor is
 (A) 0.7 eV
 (B) 0.5 eV
 (C) 2.5 eV
 (D) 1.2 eV

Ans (B)

$$E_g = \frac{hc}{\lambda} = \frac{6.6 \times 10^{-34} \times 3 \times 10^8}{2480 \times 10^{-9} \times (1.6 \times 10^{-19})} = 0.5 \text{ eV}$$

Quick calculation

E (in eV) = 
$$\frac{1240}{\lambda(nm)} = \frac{1240}{2480 (nm)} = 0.5 \text{ eV}$$

12

5. In a p-type semiconductor the acceptor level is situated 60 meV above the valence band. The maximum wavelength of light required to produce a hole in the valence band is (A)  $0.207 \times 10^{-5}$  m (B)  $2.07 \times 10^{-5}$  m (C)  $20.7 \times 10^{-5}$  m (D)  $2075 \times 10^{-5}$  m

#### Ans (B)

$$E = hv ; E = \frac{hc}{\lambda}$$
  

$$\therefore \lambda = \frac{hc}{E} = \frac{6.62 \times 10^{-34} \times 3 \times 10^8}{60 \times 10^{-3} \times 1.6 \times 10^{-19}} = 2.07 \times 10^{-5} m$$
  
Quick calculation  
12400  
12400

$$E \approx \frac{1240}{\lambda(\text{in Å})} \square \frac{1240}{\lambda(\text{in nm})} \text{ eV}$$
$$\lambda \square \frac{1240}{60 \times 10^{-3}} = 20.7 \times 10^{3} \text{ nm} = 2.07 \times 10^{-5} \text{ m}$$

6. A sample of silicon is doped with  $1.5 \times 10^5$  arsenic atoms/cm<sup>3</sup>. If the intrinsic carrier density in silicon at 300 K is  $1.5 \times 10^{10}$  / cm<sup>3</sup>, the electron density and hole density in each sample at 300 K respectively (number density is in cm<sup>-3</sup>)

- (A) are  $1.5 \times 10^{10}$ ,  $1.5 \times 10^{10}$  and the sample behaves as an intrinsic semiconductor
- (B) are  $1.5 \times 10^{10}$ ,  $1.5 \times 10^{10}$  and the sample behaves as an extrinsic semiconductor
- (C) are  $1.5 \times 10^{15}$ ,  $1.5 \times 10^{10}$  and the sample behaves as an extrinsic semiconductor
- (D) cannot be calculated with the given data

#### Ans (A)

As arsenic is a donor to a silicon crystal, the samples would tend to become n-type. As practically all the donors will be ionized at room temperature of 300 K, the extra electron density introduced will be equal to  $1.5 \times 10^5$  / cm<sup>3</sup>. As this is 5 order of magnitude lesser than the electron and hole densities in the pure sample ( $n_i = p_i = 1.5 \times 10^{10}$  / cm<sup>3</sup>), the impurity density will produce negligible changes in the original carrier densities existing in the silicon crystal due to thermal breaking of the covalent bonds. Hence, though the sample is not strictly pure, it will still show intrinsic behaviour only, and

 $n_e = n_h = 1.5 \times 10^{10} / cm^3 = n_i.$ 

#### Aliter

The impurity being arsenic, one may wrongly jump to the conclusion that the doped sample is extrinsic. The impurity concentration is  $\frac{1.5 \times 10^5}{1.5 \times 10^{10}} = 1$  atom of arsenic for every  $10^5$  atoms of the host element and it is insignificant. Hence the sample shows intrinsic behaviour

the sample shows intrinsic behaviour.

7. n-type and p-type silicon semiconductors can be obtained by doping pure silicon with

- (A) sodium and magnesium respectively (B) phosphorus and boron respectively
- (C) boron and phosphorus respectively (D) indium and sodium respectively

#### Ans (B)

Phosphorous is pentavalent and boron is trivalent material.

8. If in a p-n junction diode, a square input signal of 10 V is applied, then the value of output signal across  $R_L$  will be







$$\alpha = \left(\frac{\Delta I_C}{\Delta I_E}\right)_{v_{co}} = 0.98$$

$$\Delta I_C = 0.98 \times 2 \text{ mA} = 1.96 \text{ mA}$$

$$\Delta I_B = \Delta I_E - \Delta I_C = (2 - 1.96) \text{ mA} = 0.04 \text{ mA}$$
21. In a CE-amplifier the audio signal voltage across the collector resistance of 2 kΩ is 2V. The current amplification factor of the transistor is 100. The signal current through the base is
(A) 0.01 mA
(B) 0.1 mA
(C) 0.001 mA
(D) 0.05 mA
Ans (A)
Output ac voltage = 2V, Collector resistance = 2 kΩ
ac collector current,  $i_c = \frac{2}{2 \times 10^3} = 1 \text{ mA}$ 
Signal current, through the base,  $i_b = \frac{i_c}{\beta} = \frac{1 \times 10^{-3}}{100} = 0.01 \text{ mA}$ 
22. A transistor oscillator unit consists of a tuned circuit containing an inductance of 5 mH and a capacitance of 5 pF. The frequency of the oscillator is
(A) 100 kHz
(B) 1 GHz
(C) 10 MHz
(D) 1 MHz
Ans (D)
$$L = 5 \times 10^{-3} \text{ H}, C = 5 \times 10^{-12} \text{ F}$$

$$f = \frac{1}{2\pi\sqrt{LC}}; \quad f^2 = \frac{1}{4\pi^2 LC} \square \frac{1}{40 \times 5 \times 10^{-3} \times 5 \times 10^{-12}} = \frac{1}{10^3} \times 10^{-3} \times 10^{-12} = 10^{12}$$

$$\therefore f = \sqrt{10^2} = 10^6 \text{ Hz} = 1 \text{ MHz}$$

#### Introduction

Circuits which process continuously varying signals such as voltage or current are called *analog circuits*, while, circuits which process digital signals (pulses) are called *digital circuits*. In general, the term digital denotes variation in discrete steps. Counting by numbers (Eg, integers) is one such process. The basic device used in digital electronics is a switching element such as a diode or a transistor.

A diode in the conducting state is like a closed switch (ON-state) and in the non-conducting state is like an open switch (OFF state). In digital circuits the actual voltages are not important as long as they can drive the device to one of the two states. Since in digital circuits, there are only two states, ON and OFF, they can be conveniently represented by digits 0 and 1. These two binary digits are called *bits*. A bit can assume a value of either 0 or 1.

#### **Positive logic**

The logic in which 1 represents the high state (ON) and 0 represents the low state (OFF).

#### **Negative logic**

The logic in which 0 represents the high state (ON) and 1 represents the low state (OFF).

#### Logic gate

Information (data) to be processed by digital circuits are contained in a string of digital signals (pulses). Circuits which process this for required operations are called *logic circuits* or *logic gates*.

A logic gate has one or more inputs and an output.

*Truth table* of a logic gate is a list of its output for different possible input combinations.

#### **Boolean algebra**

George Boole evolved a process to express logical statements in terms of mathematical expressions. This theory was based on the concept of "true" or "false".

The binary digits 0 and 1 could be used to represent the "false" and "true" state respectively. The branch of algebra based on this concept is called *boolean algebra*.

There are three basic operations namely AND, OR, NOT in boolean algebra. The corresponding gates are AND gate, OR gate and NOT gate.

However, another important logic gate is the NAND gate. Using a combination of NAND gates, all other gates can be derived. Thus a NAND gate is called a *universal gate*. Similarly NOR gate can be used as a *universal gate*.

#### **OR** Gate

It performs a type of addition called OR addition. This operator is represented by "+" sign. If A and B are two variables on which OR operation is to be performed, the result Y is Logic 1 if atleast one of the variables (either A or B or both) is Logic 1. The boolean equation for OR addition is given by Y = A + B. When the variables are more than two, then the boolean equation for the OR operation is written as Y = A + B + C +----. For the four possible combinations of variables A and B, the results of OR addition are given in the truth table.





#### **AND Gate**

It performs a type of multiplication called AND multiplication. This operator is represented by • sign. If A and B are two variables on which AND operation is to be performed, the result Y is Logic 1 if ALL the variables (A and B) are Logic 1. The boolean equation for AND multiplication is given by  $Y = A \bullet B.$ 



#### **NOT Gate**

This operator can be performed on a single variable unlike AND and OR operators which require at least two variables to perform the operation.

NOT operation is nothing but inversion. The result is complement of the logic level of variable. The NOT operator is represented by writing a bar over the variable. If A is the variable, the result Y of NOT operation is written as Y = A. It is to be read as Y is NOT A. For the two possible combinations, results of the NOT operation are shown in the table.



Its boolean expression is  $Y = A \cdot B + C$ 









22



- (4) A PN-junction can act as a semiconductor diode
- 6. The conductivity of a semiconductor increases with increase in temperature because
  - (1) number density of free current carriers increases.
  - (2) relaxation time increases.
  - (3) both number density of carriers and relaxation time increase.

(4) number density of current carriers increases, relaxation time decreases but effect of decrease in relaxation time is much less than increase in number density.

7. **Statement-1**: The number of electrons in ntype semiconductor is higher than the number of electrons in a pure silicon semiconductor.

Statement-2: The law of mass action is applicable to n-type semiconductors.

- (1) Statement-1 is True, Statement-2 is True; Statement-2 is a correct explanation for Statement-1.
- (2) Statement-1 is True, Statament-2 is True; Statement-2 is NOT a correct explanation for Statement-I.
- (3) Statement-1 is True, Statement-2 is False.
- (4) Statement-1 False, Statement-2 is True.
- 8. In a p-n junction,
  - (1) new holes and conduction electrons are produced continuously throughout the material
  - (2) new holes and conduction electrons are produced continuously throughout the material except in the depletion region
  - (3) holes and conduction electrons recombine continuously throughout the material.
    (4) holes and conduction electrons recombine continuously throughout the depletion region.
- **9.** A Si and a Ge diode has identical physical dimensions. The band gap in Si is larger than that in Ge. An identical reverse bias is applied across the diodes
  - (1) The reverse current in Ge is larger than that in Si
  - (2) The reverse current in Si is larger than that in Ge
  - (3) The reverse current is identical in the two diodes
  - (4) The relative magnitude of the reverse currents cannot be determined from the given data only

## **10.** Diffusion current in a p-n junction is greater than the drift current in magnitude :-

- (1) If the junction is forward-biased
- (2) If the junction is reverse-biased
- (3) If the junction is unbiased
- (4) In no case.
- **11. Statement-1** : Transistor can act as a switch.
  - **Statement-2**: When the transistor is not conducting it is said to be switched off and when it is driven into saturation it is said to be switched on.
  - (1) Statement-I is true, Statement-II is true, Statement-II is the **correct** explanation of Statement-I

(2) Statement-I is true, Statement-II is true, Statement-II is **not** the correct explanation of Statement-I.

- (3) Statement-I is **true**, Statement-II is false.
- (4) Statement-I is **false**, Statement-II is true.
- **12.** In P-type semiconductor, drift velocity of electrons compared to holes is :



25



- 4. A solid which is not transparent to visible light and whose electrical conductivity decreases with increase in temperature is formed by
  - (1) ionic bonding
  - (2) metallic bonding
  - (3) covalent bonding
  - (4) vander Wall bonding
- 5. The electrical conductivity of pure germanium can be increased by
  - (1) increasing the temperature
  - (2) doping acceptor impurities
  - (3) doping donor impurities
  - (4) all of the above
- 6. The mobility of free electrons is greater than that of free holes because
  - (1) they are light
  - (2) they carry negative charge
  - (3) they mutually collide less
  - (4) they require low energy to continue their motion
- 7. If the two ends of a p-n junction are joined by a wire
  - (1) there will not be a steady current in the circuit
  - (2) there will be a steady current from the n-side to the p-side
  - (3) there will be a steady current from the p-side to the n-side
  - (4) there may or may not be a current depending upon the resistance of the connecting wire
- **8.** The diffusion current in a p-n junction is
  - (1) from the n-side to the p-side
  - (2) from the p-side to the n-side
  - (3) from the n-side to the p-side if the junction is forward biased and in the opposite direction if it is reversebiased
  - (4) from the p-side to the n-side if the junction is forward biased and in the opposite direction if it is reversebiased
- 9. Let  $n_p$  and  $n_e$  be the number of holes and conduction electrons in an extrinsic semiconductor. Then
  - (1)  $n_p > n_e$  (2)  $n_p = n_e$  (3)  $n_p < n_e$  (4)  $n_p \neq n_e$
- **10.** In the half wave rectifier circuit operating from 50 Hz mains frequency, the fundamental frequency in the ripple would be
  - (1) 25 Hz (2) 50 Hz (3) 70.7 Hz (4) 100 Hz
- 11. In a half wave rectifier, the r.m.s. value of the a.c. component of the wave is
  - (1) equal to d.c. value
  - (2) more than d.c. value

	(3) less than d.c. value	2		
	(4) zero			
12.	The average value of	output direct current in	a full wave rectifier is	
	(1) $I_0/\pi$	(2) $I_0/2$	(3) $\pi I_0/2$	(4) 2 I <sub>0</sub> /p
13.	Carbon, Silicon and G	Germanium atoms have	e four valence electron	ns each. Their valence and conduction
	bands are separated by	y energy band gaps rep	resented by $(E_g)_C$ , $(E_g)_S$	si and $(E_g)_{Ge}$ respectively. Which one of
	the following relation	ship is true in their case	e?	
	(1) $(E_g)_C > (E_g)_{Si}$	(2) $(E_g)_C < (E_g)_{Si}$	(3) $(E_g)_C = (E_g)_{Si}$	(4) $(E_g)_C < (E_g)_{Ge}$
14.	A light emitting diode	is shown as		
	N			
		(2)	(3)	(4)
15.	The I-V characteristic	of an LED is		
16.	In a p-type semicond	uctor the acceptor leve	1 is situated 60 meV a	bove the valence band. The maximum
	wavelength of light re	equired to produce a ho	le will be	emv
	(1) $0.207 \times 10^{-5}$ m	(2) $2.07 \times 10^{-5}$ m	(3) $20.7 \times 10^{-5}$ m	(4) $2075 \times 10^{-5}$ m
17.	For bidden gap for ins	sulators is		
	$(1) \ge 6eV$	$(2) \leq 1 \text{ eV}$	$(3) \leq 3 \text{ eV}$	$(4) \cong 0 \text{ eV}$
18.	Copper, a monovalent	t, has molar mass 63.54	4 g/mol and density 8.9	96 g/cm <sup>3</sup> . What is the number density n
	of conduction electron	n in copper?		
	(1) $1.1 \times 10^{26} \text{ m}^{-1}$	(2) $2.8 \times 10^{25} \text{ m}^{-1}$	(3) $8.49 \times 10^{28} \text{ m}^{-1}$	(4) None of these
19.	An LED is constructe	ed from a p-n junction	based on a certain Ga	-As -P semiconducting material whose
	energy gap is 1.9 eV.	What is the wavelengtl	n of the emitted light?	
	(1) 150 nm	(2) 350 nm	(3) 500 nm	(4) 650 nm
20.	In a photodiode, the	conductivity increases	when the material is	exposed to light. It is found that the
	conductivity changes	only if the wavelength	is less than 620 nm. W	/hat is the band gap?
	(1) 1.0 eV	(2) 3.2 eV	(3) 6 eV	(4) 2.0 eV
21.	The energy gap of sili	con is 1.14 eV. The ma	aximum wavelength at	which silicon starts energy absorption,
	will be $(h = 6.62 \times 10)$	$^{-34}$ Js ; c = 3 × 10 <sup>8</sup> m/s)	)	
	(1) 10.888 Å	(2) 108.88 Å	(3) 1088.8 Å	(4) 10888 Å
22.	On doping germaniun	n with donor atoms of c	density $10^{17}$ cm <sup>-3</sup> its co	onductivity in mho/cm will be
	[Given : $\mu_e = 3800$ cm <sup>2</sup>	$^{2}/V-s$ and $n_{i} = 2.5 \times 10^{2}$	$^{13} \text{ cm}^{-13}$ ]	
	(1) 30.4	(2) 60.8	(3) 91.2	(4) 121.6

23.	The ratio of electro	n and hole currents	in a semiconductor is 7/4 a	and the ratio of drift velocities of electr	ons
	and holes is 5/4, the	en the ratio of conce	entrations of electrons and	holes will be	
	(1) 5/7	(2) 7/5	(3) 25/49	(4) 49/25	
24.	What is the conduc	ctivity of a semicor	nductor if electron densit	$y = 5 \times 10^{12}$ /cm <sup>3</sup> and hole density =	8 ×
	$10^{13}$ /cm <sup>3</sup> ( $\mu_e = 2.3$ m	$m^2 V^{-1} s^{-1}, \mu_h = 0.01$	$m2V^{-1} s^{-1}$ )		
	(1) 5.634	(2) 1.968	(3) 3.421	(4) 8.964.	
25.	If the ratio of the co	oncentration of elect	rons to that of holes in a s	emiconductor is $\frac{7}{5}$ and the ratio of current	ents
	$is\frac{7}{4}$ , then what is the the transformation of trans	he ratio of their drift	velocities?		
	(1) $\frac{5}{8}$	(2) $\frac{4}{5}$	(3) $\frac{5}{4}$	(4) $\frac{4}{7}$	
26.	In germanium the e	energy gap is about (	).75 eV. The wavelength o	of light which germanium starts absorb	ing
	is				
	(1) <mark>500</mark> 0 Å	(2) 1650 Å	(3) 16500 Å	(4) 165000 Å	
27.	A potential barrier	of 0.3 V exists acro	oss a p-n junction. An ele	ctron with speed 5 × 105 m/s approac	hes
	thi <mark>s p</mark> -n junction fro	om n-side, what will	be its speed on entering t	the p-side?	
	(1) $3 \times 10^5$ m/s	(2) $3.8 \times 10^5$ m	1/s (3) 5 × 10 <sup>5</sup> m/s	(4) $2.6 \times 10^3$ m/s	
28.	For a junction diod	e the ratio of forwar	d current (I <sub>f</sub> ) and reverse	current (I <sub>r</sub> ) is	
	[e = <mark>ele</mark> ctronic char	·ge,			
	V = voltage applied	l across junction,			
	k = Boltzmann con	stant,			
	T = temperature in	kelvin]			
	(1) $e^{-V/kT}$	(2) $e^{V/kT}$	(3) $(e^{-eV/kT} + 1)$	(4) $(e^{eV/kT} - 1)$	
		Торіс	2: Junction Transis	stor	
29.	Transistor working	as an amplifier ope	rates in its active region o	nly when	
	(1) the emitter junc	tion is forward biase	ed and the collector juncti	on is reverse biased	
	(2) the emitter junc	tion is reverse biase	d		
	(3) the collector jur	nction is forward bia	used		
	(4) the emitter junc	tion is reverse biase	d and the collector junction	on is forward biased	
30.	Current gain of a tr	ansistor in common	base mode is 0.95. Its val	lue in common emitter mode is	
	(1) 0.95	(2) 1.5	(3) 19	$(4) (19)^{-1}$	
31.	A transistor has $\beta$ =	= 40. A change in ba	se current of 100 mA, pro	oduces change in collector current	
	(1) $40 \times 100$ micros	ampere			
	(2) (100 – 40) micr	oampere			
	(3)(100+40) micr	oampere			

(4) 100/40 microampere

**32.** In a common base amplifier the phase difference between the input signal voltage and the output voltage is

(1) 0 (2)  $\pi/4$  (3)  $\pi/2$  (4)  $\pi$ 

**33.** The current gain b may be defined as

(1) the ratio of change in collector current to the change in emitter current for a constant collector voltage in a common base arrangement.

(2) the ratio of change in collector current to the change in the base current at constant collector voltage in a common emitter circuit

(3) the ratio of change in emitter current to the change in base current for constant emitter voltage in common emitter circuit.

(4) the ratio of change in base current to the change in collector current at constant collector voltage in common emitter circuit.

**34.** When n-P-n transistor is used as an amplifier, then

(1) electrons move from collector to emitter

(2) electrons move from emitter to collector

(3) electrons move from collector to base

(4) holes move from emitter to collector

**35.** In a transistor

(1) both emitter and collector have same length

(2) length of emitter is greater than that of collector

(3) length of collector is greater than that of emitter

(4) any one of emitter and collector can have greater length

**36.** If the given transistor is used as an amplifier then for input resistance of  $80 \Omega$  and load resistance of  $16k \Omega$ , the output voltage corresponding to the input voltage of 12mV will be

(1) 37.5 mV (2) 37500 V (3) 300 V (4) 300 mV

**37.** When the base current in a transistor is changed from 30  $\mu$ A to 80  $\mu$ A, the collector current is changed from 1.0 mA to 3.5 mA. Find the current gain  $\beta$ .

(1) 30 (2) 40 (3) 45 (4) 50

38. A transistor is connected in common -emitter configuration. The collector supply is 8V and the voltage drop across a resistor of 800 W in the collector is 0.5 V. If the current gain factor α is 0.96. Find the base current.

(1)  $5 \mu A$  (2)  $6 \mu A$  (3)  $20 \mu A$  (4)  $26 \mu A$ 

**39.** A pnp transistor is used in common-emitter mode in an amplifier circuit. A change of 40  $\mu$ A in the base current brings a change of 2 mA in collector current and 0.04 V in base emitter voltage. If a load of 6k  $\Omega$  is used, then also find the voltage gain of the amplifier.

(1) 1 (2) 50 (3) 300 (4) 900

40.	In a npn transistor	10 <sup>10</sup> electrons enter the	emitter in 10 <sup>-6</sup> s.	4% of the electrons	are lost in the base. The
	current transfer ratio	o will be			
	(1) 0.98	(2) 0.97	(3) 0.96	(4) 0.94	
41.	The current gain of	a transistor in common	base mode is 0.99	95. The current gain	of the same transistor in
	common emitter mo	ode is			
	(1) 197	(2) 201	(3) 198	(4) 199	
42.	A working transisto	r with its three legs man	rked $P, Q$ and $R$ is	s tested using a multi	meter. No conduction is
	found between P and	nd $Q$ . By connecting the	e common (negat	ive) terminal of the	multimeter to R and the
	other (positive) terr	ninal to $P$ or $Q$ , some respectively.	esistance is seen o	on the multimeter. W	hich of the following is
	true for the transisto	or?			
	(1) It is an npn trans	sistor with R as base			
	(2) It is a pnp transi	stor with <i>R</i> as collector			
	(3) It is a pnp transi	stor with R as emitter			
	(4) It is a pnp transit	stor with R as base			
43.	A transistor has the	ee impurity regions. A	Il the three regio	ns have different do	ping levels. In order of
	increasing doping le	evel, the regions are			
	(1) emitter, base and	l collector	(2) collector, b	base and emitter	
	(3) base, emitter and	d collector	(4) base, collec	ctor and emitter	
44.	A transistor has a ba	ase current of 1 mA and	emitter current 90	0 mA. The collector of	current will be
	(1) 90 mA	(2) 1 mA	(3) 89 mA	(4) 91 mA	
45.	In a common emitte	r transistor amplifier $\beta$	$= 60, R_{\rm o} = 5000 \Omega$	2 and internal resista:	nce of a transistor is 500
	$\Omega$ . The voltage amplitude $\Omega$	plification of amplifier v	will be		
	(1) 500	(2) 460	(3) 600	(4) 560	
46.	Operating point of a	transistor is			
	(1) zero signal value	e of $V_{CC}$ and $I_b$	(2) zero signal	value of I <sub>c</sub>	
	(3) zero signal value	e of V <sub>cc</sub>	(4) zero signal	value of $I_c$ and $V_{CE}$	
47.	The main difference	between voltage and p	ower amplifiers is	that	
	(1) power amplifier	handles current	(2) power amp	lifier handles large v	oltage
	(3) power amplifier	handles large power	(4) None of the	ese	
		Topic 3: Digital El	ectronics an	d Logic Gates	
48.	The device that can	act as a complete electr	onic circuit is		
	(1) junction diode	(2) integrate	ed circuit (3) june	ction transistor	(4) zener diode
49.	What is the value of	A.C + A.B.C where A,	, B and C are inpu	ts?	
	(1) A.C	(2) A.B	(3) A	(4) B	
50.	The output of an Ol	R gate is connected to b	oth the inputs of a	a NAND gate. The co	ombination will serve as
	a:				









[2014]



Which of the following statement is correct?

(1) It is V - I characteristic for solar cell where, point A represents open circuit voltage and point B short circuit current.

(2) It is a for a solar cell and point A and B represent open circuit voltage and current, respectively.

(3) It is for a photodiode and points A and B represent open circuit voltage and current, respectively.

(4) It is for a LED and points A and B represent open circuit voltage and short circuit current, respectively.

#### **14**.



	Th <mark>e co</mark> rrect Bool	lean operation r	epresented by	the circuit diagr	am drawn is :	[NEET – 2019]
	(1) AND	(2) OR	(3) NAND	(4) NOR		
15.	For a p-type sem	niconductor whi	ch of the follo	wing statements	is true?	[NEET – 2019]
	(1) Electrons are	the majority ca	rriers and triva	alent atoms are t	he dopants.	
	(2) Holes are the	majority carrie	ers and trivalen	t atoms are the o	dopants.	
	(3) Holes are the	majority carrie	ers and pentava	lent atoms are t	he dopants.	
	(4) Electrons are	the majority ca	arriers and pent	tavalent atoms a	re the dopants.	
<b>16</b> .	An LED is const	tructed from a p	-n junction die	ode using GaAsI	P. The energy g	ap is 1.9 eV. The
	wavelength of th	e light emitted	will be equal to	0:-		[NEET – 2019 (ODISSA)]
	(1) $10.4 \times 10^{-26}$	m (2) 654	nm (3) 654	Å (4) 654	$\times 10^{-11} \mathrm{m}$	
17.	The circuit diagr	am shown here	corresponds to	o the logic gate,		[NEET – 2019 (ODISSA)]



2) Base, emitter and collector regions should have same doping concentration 3) Base, emitter and collector regions should have same size 4) Both emitter junction as well as the collector junction are forward biased 24. [NEET - 2020]For the logic circuit shown the truth table is B 1) A Y 2) Y В А B 0 0 1 0 0 0 0 1 0 0 0 1 1 0 0 0 0 1 1 1 1 0 1 1 3) В 3) В Y А γ А 0 0 0 0 0 1 1 0 1 0 1 1 0 0 1 1 1 1 0 1 1 1 1 1 25. The electron concentration in an n-type semiconductor is the same as hole concentration in a p-type semiconductor. An external field (electric) is applied across each of them. Compare the currents in them [NEET-2021] 1) current in p-type > current in n-type 2) current in n-type > current in p-type 3) No current will flow in p-type, current will only flow in n-type 4) current in n-type = current in p-type **26**. Consider the following Statements (1) and (2) and identify the correct answer. [NEET-2021] (1) A zener diode is connected in reverse bias, when used as a voltage regulator. (2) The potential barrier of p-n junction lies between 0.1 V to 0.3 V 1) (1) and (2) both are incorrect 2) (1) is correct and (2) is incorrect 3) (1) is incorrect but (2) is correct 4) (1) and (2) both are correct 27. For the given circuit, the input digital signals are applied at the terminals A, B and C. What would be the output at the terminal y? [NEET-2021] B C



# NCERT LINE BY LINE QUESTIONS – ANSWERS

1) b	2) d	3) b	4) b	5) a	6) b	7) c	8) c	9) b	10) a
11) d	12) a	13) b	14) c	15) b	16) d	17) a	18) b	19) d	20) c

# NCERT BASED PRACTICE QUESTIONS - ANSWERS

1) 1	2) 4	3) 2	4) 4	5) 3	6) 4	7) 2	8) 1	9) 1	10) 1	
11) 1	12) 1	13) 4	14) 1	15) 1	16) 2	17) 4	18) 3	19) 2	20) 4	21) 1

# **TOPIC WISE PRACTICE QUESTIONS - ANSWERS**

1)	2	2)	3	3)	3	4)	2	5)	4	6)	1	7)	1	8)	2	9)	4	10)	2
11)	2	12)	4	13)	1	14)	4	15)	1	16)	2	17)	1	18)	3	19)	4	20)	4
21)	1	22)	2	23)	2	24)	2	25)	3	26)	3	27)	2	28)	4	29)	1	30)	3
31)	1	32)	1	33)	2	34)	2	35)	3	36)	3	37)	4	38)	4	39)	3	40)	3
41)	4	42)	4	43)	4	44)	3	45)	3	46)	4	47)	2	48)	2	49)	1	50)	2
51)	3	52)	2	53)	4	54)	2	55)	2	56)	1	57)	4	58)	1	59)	2	60)	3

# **NEET PREVIOUS YEARS QUESTIONS-ANSWERS**

1)	3	2)	3	3) 2	4)	4	5)	2	6) 2	X	7) 2	8)	1	9)	4
10)	3	11)	4	12) 3	13)	1	14)	3	15) 2		16) 2	17)	1	18)	4
19)	3	20)	3	21) 1	22)	3	23)	1	24) 2		25) 2	26)	2	27)	3
28)	3	29)	3	30) 4	31)	3									

# **TOPIC WISE PRACTICE QUESTIONS - SOLUTIONS**

- 1. (2) The electrical conductivity of a semiconductor at 0 K is zero. Hence resistivity (= 1/electrical conductivity) is infinity.
- 2. (3) majority carriers in both regions
- 3. (3) By doping, the band gap reduce from 1eV to 0.3 to 0.7 eV & electron can achieve this energy (0.3eV to 0.7eV) at room temperature & reach in C.B (conduction band).
- 4. (2) A solid is not transparent to visible light if the value of wavelength of light is greater than the bond length between the atoms/molecules/ions of material. Conductivity depends upon the no. of free charge carriers present in the substance at a given temperature or resistance of that material at that temperature.
- 5. (4) As the temperature increases, the thermal motion of electrons also increases which results in increasing of the conductivity of the Ge crystal.

Also as the conductivity of extrinsic semiconductor is more than that of intrinsic semiconductor, thus the conductivity of pure germanium increases by doping Ge crystal either with acceptor impurities or the donor impurities.

- 6. (1) The mobility of free electrons is greater than that of free holes because there are light
- 7. (1) If the two ends of a p-n junction are joined by a wire then there will not be a steady current in the circuit.
- 8. (2) The diffusion current in a p-n junction is from the p-side to n-side.
- 9. (4) In extrinsic semi conductor the number of holes are not equal to number of electrons i.e.,

 $n_p \neq n_e$ 

In p - type  $n_p > n_e$ 

In n - type  $n_e > n_p$ 

But over all both p & n - type semi-conductor are uncharged.

- 10. (2) In half wave rectifier, we get the output only in one half cycle of input a.c. therefore, the frequency of the ripple of the output is same as that of input a.c. i.e. 50 Hz
- 11. (2) The r.m.s. value of a.c. component of wave is more than d.c. value due to barrier voltage of p-n junction used as rectifier.

12. (4) The average value of output direct current in a full wave rectifier = average value of current over a cycle  
= 2 lo 
$$\pi$$
  
13. (1) Due to strong electronegativity of carbon.  
14. (4)  $\int_{1}^{\infty}$  light emitting diode  
15. (1) For LED, in forward bias, intensity increases with voltage.  
16. (2)  $\lambda = \frac{hc}{E} = \frac{6.62 \times 10^{-8} \times 3 \times 10^{8}}{(60 \times 10^{-3} \times 1.6 \times 10^{-9})} = 2.07 \times 10^{-4} \text{m}}$   
17. (1) In an insulator the forbidden band gap is of the order of  $\geq 6eV$   
18. (3)  $8.49 \times 10^{3} \text{m}^{-1}$   
19. (4) If  $\lambda$  is the wavelength of emitted light, then  
 $F_{x} = \frac{hc}{h} \Rightarrow \lambda = \frac{hc}{E}$   
 $= \frac{(6.63 \times 10^{-4}) \times (3 \times 10^{9})}{(1.9) \times (1.60 \times 10^{-9})} = 6.5 \times 10^{-9} \text{ m} = 650 \text{ nm}$   
20. (4) The band gap  $E_{g}$   
 $= \frac{(6.63 \times 10^{-24}) \times (3 \times 10^{19})}{620 \times 10^{-20}} = 6.2 \times 10^{-19} \text{ J} = 2.0 \text{ eV}.$   
11. (1)  $\lambda = \frac{hc}{E} = \frac{6.62 \times 10^{-44} \times 3 \times 10^{4}}{(1.44 \times 1.60 \times 10^{-9})} = 10.888 \text{ A}$   
22. (2) Conductivity  $\sigma = n.et_{w} = 10^{17} \times (1.6 \times 10^{-9}) \times 3800 = 60.8 \text{ mbolem}$   
23. (2) I = nAev<sub>0</sub> or 1 a n<sub>0</sub>  
 $\therefore \frac{1}{k} = \frac{n}{n_{w}v_{w}} \text{ or } \frac{n}{n_{w}} = \frac{1}{k_{w}} \frac{v_{w}}{v_{w}} = \frac{7}{4} \times \frac{4}{5} = \frac{7}{5}$   
24. (2) Given ty = 2.2 an<sup>2</sup>V + s<sup>-1</sup>  
 $y_{h} = 0.01 \text{ m}^{2}V^{-1} s^{-1}$   
 $= 1.6 \times 10^{-19} \text{ IS} \times 10^{13} \times 2.3 + 8 \times 10^{19} \text{ m}^{-1}$   
25. (3)  $\frac{1}{k_{w}} = \frac{n_{w}ev_{w}}{n_{w}} = \frac{7}{k_{w}} \times \frac{5}{v_{w}} = \frac{5}{k_{w}} = \frac{4}{k_{w}} = \frac{6.63 \times 10^{-34} \times 3.10^{6}}{(.75 \times 1.6 \times 10^{-9})} \approx 10^{19} \times 10^{13} \times 10^{10} \text{ m}^{-3} \times 10^{19} \text{ m}^{-3} \times 10^{19} \text{ m}^{-3} = 1.6 \times 10^{-19} \text{ m}^{-3} \times 10^{19} \text{ m}^{-1} = 1.6 \times 10^{-19} \text{ II J 3} = 1.988 \text{ M}^{-1} \text{ m}^{-1} = 1.6 \times 10^{-19} \text{ II J 3} = 1.988 \text{ M}^{-1} \text{ m}^{-1} = 1.6 \times 10^{-19} \text{ m}^{-1} = \frac{1}{k_{w}} \frac{v_{w}}{v_{w}} = \frac{7}{4} \times \frac{4}{5} = \frac{7}{5}$   
26. (3)  $\frac{1}{k_{w}} = \frac{n_{w}ev_{w}}}{n_{w}} = \frac{1}{k_{w}} \frac{v_{w}}{v_{w}} = \frac{7}{4} \times \frac{5}{5} = \frac{5}{5}$   
27. (2) The intensity of electric field returbed in the electron. The retardation a = E\_{em} The speed of the electron on entering

**29.** (1) For transistor as an amplifier, emitter-base has to be in forward bias and collector base has to be in reverse bias.

**30.** (3) 
$$\beta = \frac{\alpha}{1-\alpha} = \frac{0.95}{1-0.95} = \frac{0.95}{0.05} = 19$$

**31.** (1) 
$$\beta = \frac{\Delta I_{\rm C}}{\Delta I_{\rm B}}$$
 or  $\Delta I_{\rm C} = \beta \Delta I_{\rm B} = 40 \times 100 \mu \text{A}$ 

- **32.** (1) The phase difference between output voltage and input signal voltage in common base transistor circuit is zero
- **33.** (2) the ratio of change in collector current to the change in the base current at constant collector voltage in a common emitter circuit
- 34. (2) electrons move from emitter to collector
- **35.** (3) length of collector is greater than that of emitter

36. (3) Current 
$$gain \beta = \frac{\Delta I_C}{\Delta I_B} = \frac{(15-10) \text{ mA}}{(80-40) \mu \text{A}}$$
  

$$= \frac{5 \times 10^{-3}}{40 \times 10^{-6}} = \frac{5000}{40} = 125$$

$$A_v = \beta \frac{R_L}{R_m}; \frac{V_{out}}{V_{in}} = 125 \left(\frac{16 \times 10^3}{80}\right)$$

$$V_{out} = 125 \times \frac{16000}{80} \times 12 \times 10^{-3} = 300 \text{ V}$$

37. (4) We know that 
$$\beta = \frac{\Delta I_C}{\Delta I_B} = \frac{(3.5 - 1.0) \times 10^{-6}}{(80 - 30) \times 10^{-6}} = 50^{-6}$$

**38.** (4) We know that 
$$\beta = \frac{\alpha}{1-\alpha} = \frac{0.96}{1-0.96} = 24$$
  
The collector current is  $i_C = \frac{V_C}{T} = \frac{0.5}{2300} = 0.625 \times 10^{-3} \text{ A}$ 

Base current 
$$i_B = \frac{i_C}{\beta} = \frac{0.625 \times 10^{-3}}{24} = 26 \times 10^{-6} A = 26 \mu A$$

**39.** (3) Voltage gain in common-emitter configuration is given by

$$A_v = \beta \frac{R_L}{R_{in}} = 50 \times \frac{6 \times 10^3}{1 \times 10^3} = 300$$

40. (3) No. of electrons reaching the collector

$$n_{\rm C} = \frac{96}{100} \times 10^{10} = 0.96 \times 10^{10}$$

Emitter current,  $I_E = \frac{n_E \times e}{t}$ 

Collector current, 
$$I_C = \frac{n_C \times e}{t}$$

:. Current transfer ratio,

$$\alpha = \frac{I_C}{I_E} = \frac{n_C}{n_E}$$
$$\frac{0.96 \times 10^{10}}{10^{10}} = 0.96$$

41. (4) Current gain in common emitter mode  $= \frac{\alpha}{1-\alpha} = \frac{0.995}{1-0.995} = \frac{0.995}{0.005} = 199$ 42. (4) It is a superior emitter provide P as here. Now explain

42. (4) It is a p-n-p transistor with R as base. None of the

option is correct.

- **43.** (4) base, collector and emitter
- **44.** (3)  $I_c = I_E I_B = 90 1 = 89 \text{mA}$

**45.** (3) Voltage amplification 
$$A_v = \beta \frac{R_o}{R_i} = 60 \times \frac{5000}{500} = 600$$

- 46. (4) Operating point of a transistor is zero signal value of  $I_c$  and  $V_{CE}$ .
- **47.** (2) The power amplifier handles large power
- **48.** (2) Integrated circuit can act as a complete electronic circuit.
- **49.** (1) The values of A.C + A.B.C is A.C
- **50.** (2)  $\left(\overline{A+B}\right) = NOR$  gate

When both inputs of NAND gate are connected, it behaves as NOT gate

OR + NOT = NOR

- 51. (3) When the two inputs of a NAND gate are shorted, the resulting gate is NOT
- **52.** (2)  $X = 1 = A \times B \times (\overline{BC})$

Therefore, A = 1, B = 1, C = 0

- 53. (4) The logic gate (3) is a NAND gate for which the Boolean expression is  $X = \overline{0.1}$ We have  $X = \overline{0} = 1$ .
- 54. (2) Combination of NAND & NOR gates can produce OR, AND & NOT gates
- **55.** (2) Truth table is as shown:

Α	в	Ā	$\overline{\mathbf{B}}$	$\overline{A} + \overline{B}$	$\overline{\overline{A}} + \overline{\overline{B}}$	
0	0	1	1	1	0	
0	1	1	0	1	0	
1	0	0	1	1	0	
1	1	0	0	0	1	

Thus the combination of two NOT gates and one NOR gate is equivalent to a AND gate

- 56. (1) A and B are the inputs of an OR gate. If A = 1, and B = 0, the output of OR gate will be 1. Now the output of OR gate along with C make the inputs of an AND gate.
- 57. (4) NAND and NOR gates are called universal gates.
- **58.** (1)



- 59. (2) Output of upper AND gate =  $\overline{AB}$ Output of lower AND gate =  $A\overline{B}$  $\therefore$  Output of OR gate, Y =  $A\overline{B} + B\overline{A}$
- 60. (3)  $(W + X) \cdot (W + Y) = W + (X \cdot Y)$

# **NEET PREVIOUS YEARS QUESTIONS-EXPLANATIONS**

- (3) On heating, number of electron-hole pairs increases, so overall resistance of diode will change. Hence forward biasing and reversed biasing both are changed.
- 2. (3) The values of  $I_B$ ,  $I_C$  and  $\beta$  are given by

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$$I_{g} = 40 \mu A_{1}I_{c} = 5ma, \beta = 125$$

$$V_{a} = l_{B}R_{B} + V_{B2}$$

$$20 = l_{B} \times (500 \times 10^{3}) + 0$$

$$l_{B} = \frac{50}{500 \times 10^{3}} = 40 \mu A$$

$$V_{CC} = l_{C}R_{C} + V_{CC}$$

$$20 = l_{C} \times (4 \times 10^{3}) + 0$$

$$l_{C} = 5 \times 10^{3} = 5 \text{ mA}$$

$$\beta = \frac{L}{L} = \frac{5 \times 10^{3}}{40 \cdot 10^{5}} = 125$$
3. (2)  

$$A = \frac{1}{L} = \frac{5 \times 10^{3}}{40 \cdot 10^{5}} = 125$$
3. (2)  

$$A = \frac{1}{L} = \frac{5 \times 10^{3}}{40 \cdot 10^{5}} = 125$$
3. (2)  

$$A = \frac{1}{L} = \frac{5 \times 10^{3}}{40 \cdot 10^{5}} = 125$$
3. (2)  

$$A = \frac{1}{L} = \frac{100}{4} = \frac{100}{4} = \frac{100}{2} = 150$$
Power gain (A<sub>1</sub>)=  $\beta \frac{R_{L}}{R_{L}} = 100(\frac{3}{2}) = 150$ 
Power gain (A<sub>2</sub>)=  $\beta \frac{R_{L}}{R_{L}} = 100(\frac{3}{2}) = 150$ 
Power gain = A, \beta = 150 (100) = 15000  
6. (2)  

$$A = \frac{1}{L} = \frac{100}{4} = \frac{100}{4$$

8. (1) Transistor is working in common emitter configuration. Hence, input terminal is at base and output terminal is at collector.

Given:

 $R_c=800\Omega$ ,  $V_L=0.8V$ ,  $R_B=192\Omega$ Current amplification factor =0.96

Hence, 
$$\frac{I_C}{I_B} = 0.96$$

Assumption:

Transistor is ideal and working in forward active region (Junction BE is forward biased and Junction BC is reverse biased).

$$\Rightarrow$$
V<sub>BE</sub>=0; V<sub>E</sub>=0 $\Rightarrow$ V<sub>B</sub>=0

Collector current is given by  $I_C = V_L/R_c = 0.8/800 = 10^{-3} A$ 

Base current is given by,  $I_B = I_C / \beta = 0.9610^{-3} A$ 

Applying  $\frac{\text{KVL}}{\text{VL}}$  on Base circuit, input voltage  $V_{BB}=I_BR_B$ 

$$V_{BB} = \frac{10^{-3}}{0.96} \times 192 = 0.2V$$
Voltage Gain,  $A_v = \frac{V_{out}}{V_{in}} = \frac{V_L}{V_{BB}} = \frac{0.8}{0.2} = 4$ 
Current Gain,  $A_I = \frac{I_{out}}{I_{in}} = \frac{I_C}{I_B} = \beta = 0.96$ 
Power Gain,  $A_P = A_V A_I = 4 \times 0.96 = 3.84$ 

9. (4) From left side the first gate is OR gate and next one is AND gate. So the out put of OR gate is A+B and the output of AND gate Y=(A+B).C

We know that for AND gate the put will be 1 if both inputs are 1. So, A+B=1 and C=1

In logic gate, 1+0=1 so A=1,B=0,C=1 will be the correct choice for output 1.

10. (3) Here P-N junction diode rectifies half of the ac wave i.e., acts as half wave rectifier. During + ve half cycle

5V

Diode  $\rightarrow$  forward biased output across will be

During –ve half cycle Diode  $\rightarrow$  reverse biased output will not obtained.

**11.** (4) Current I = 
$$\frac{V}{R} = \frac{(3.5 - 0.5)}{100} A$$
  
[... Barrier potential V<sub>B</sub> = 0.5V

[ $\cdot$ .• Barrier potential V<sub>B</sub> = 0.5V] **12.** (3) Given : Voltage gain AV = 150

$$\mathbf{V}_{i} = 2\cos\left(15t + \frac{\pi}{3}\right); \mathbf{V}_{0} = ?$$

For CE transistor phase difference between input and output signal is  $\pi = 180^{\circ}$  Using formula

$$A_{v} = \frac{V_{0}}{V_{i}} \Longrightarrow V_{0} = A_{v} \times V_{i}$$
$$= 150 \times 2\cos\left(15t + \frac{\pi}{3}\right) \text{ or } V_{0} = 300\cos\left(15t + \frac{\pi}{3} + \pi\right)$$
$$V_{0} = 300\cos\left(15t + \frac{4}{3}\pi\right)$$

13. (1) The given graph represents V-I characteristics of solar cell.

B Α Y 0 0 1 0 1 1 1 1 0 1 1 0 It is a NAND Gate

**15.** For P type

14.

Holes are majority & trivalent atoms are the dopants

- **16.**  $\lambda = \frac{1240nm}{10} = 652.6nm \ 654nm$
- 13. *n* = 1.9 17. A B 0 0

0

1

- $\begin{array}{c|c} 1 & 1 & 0 \\ 18. & \text{In forward bias } V_P > V_N \end{array}$
- **19.** Voltage drop across load resistance = 0.8 V

Y

1 0

$$I_{\rm C} = \frac{V_{\rm C}}{R_{\rm C}} = \frac{0.8}{80} = 10^{-3} \rm{A} = 1 \rm{mA}$$

- **20.** NAND gate and NOR gate are universal logic gates.
- 21. For N type semi-conductor intrinsic semi conductor doped by pentavalent impurity.
- 22. Height of potential barrier increases in reverse bias only
- 23. For a transistor base junction must be very thin and lightly doped

24.	$Y = \overline{A} + \overline{B} = \overline{A}.\overline{B} = A.B$					
	So tl	ne give	logic ga	ate acts as	s AND ga	te
	Α	В	Y			
	0	0	0			
	0	1	0			
	1	0	0			
	1	1	1			
25.	Mobility of electrons > mobility of holes					
26.	Potential barrier of p-n junction can be up to 0.7 v					
27.	А	В	С	A.B	$\overline{B.C}$	output
	0	0	1	0	1	1
	1	0	1	0	1	1
	0	1	0	0	1	1
	1	1	0	1	1	1

28 For conductors with increase in temperature, resistance increases and for semiconductors resistance decreases. 29. For half wave rectifier Input frequency = output frequency  $\therefore n = 60Hz$ *a* and *c* are forward biased 30  $C = \left(\overline{A.B}\right) \cdot \left(\overline{\overline{A}.B}\right)$ 31.  $= \left(\overline{A} + \overline{B}\right) \cdot \left(A + \overline{B}\right) = \left(\overline{A} \cdot A + \overline{A} \cdot \overline{B} + \overline{B} A + \overline{B} \cdot B\right)$  $= O + \overline{B}(\overline{A} + A + 1) = \overline{B}$